

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Keisuke KAWAMURA, et al.

SERIAL NO: 10/519,475

GAU: 1792

FILED: December 28, 2004

EXAMINER: ARANCIBIA, M. G.

FOR: PLASMA PROCESSING SYSTEM AND ITS SUBSTRATE PROCESSING
PROCESS, PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION
SYSTEM AND ITS FILM DEPOSITION PROCESS

REQUEST FOR EXTENSION OF TIME
UNDER 37 C.F.R. 1.136

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

It is hereby requested that a **one** month extension of time be granted to November 11, 2008, for

☒ filing a response to the Official Action dated: July 11, 2008.

☐ responding to the requirements in the Notice of Allowability dated:

☐ filing the Formal Drawings. The Issue Fee due has been timely filed.

☐ responding to the Notice to File Missing Parts of Application dated:

☐ filing a Notice of Appeal. A timely response to the final rejection, due has been filed.

☐ filing an Appeal Brief. A Notice of Appeal was filed on:

☐ Applicant claims small entity status. See 37 CFR 1.27.

The required fee of \$130.00 is being made by credit card payment online (if electronically filed), or is attached hereto (if paper filed), and any further charges may be made against the Attorney of Record's Deposit Account No. 15-0030.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,
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